Attorney Docket No. **10112971**

PATENT

JAN 18 2006

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:	**Ching-Wei LIN**	Filed:	**10/3/2003**
Appl. No.:	**10/678,908**	Examiner:	**EVERHART, CARIDAD**
Conf. No.:	**2225**	Art Unit:	**2891**

Title: **PROCESS FOR PASSIVATING POLYSILICON AND PROCESS FOR FABRICATING POLYSILICON THIN FILM TRANSISTOR**

Date: **January 18, 2006**

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

The Office Action mailed on **October 19, 2005** has been carefully considered. In response thereto, the Applicant respectfully requests entry of the amendments and consideration of the remarks as set forth herein below:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 5 of this paper.

All amendments and remarks made herein are without prejudice.

PAGE 4/15 * RCVD AT 1/18/2006 6:54:14 PM [Eastern Standard Time] * SVR:USPTO-EFXRF-6/27 * DNIS:2738300 * CSID:310 401 6185 * DURATION (mm-ss):05-06